

Success Story

NOVEL APPROACH FOR RECLAIMING SEMICONDUCTOR WASTEWATER SAVES OPERATIONAL COSTS

Gradiant was uniquely qualified to deliver a resilient solution to treat and reuse wastewater for one of the largest global semiconductor manufacturers. The custom-designed system combined proprietary and conventional technologies to ensure robust treatment and reliable recovery. The client is also realizing higher recovery and additional capacity as the system is optimized.

The Challenge

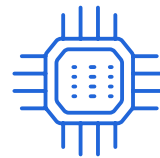
One of the largest global semiconductor manufacturers contemplated numerous approaches to achieve water reuse targets issued by the local Science Park in Taiwan. Not only did the wastewater contain variable concentrations of total organic carbon, ammonia, and nitrates, but the space available for implementing a new treatment plant was minimal. This combination of design challenges, along with the intricacy of managing the project without disrupting ongoing operations, proved to be too onerous for several providers, except for Gradiant.

The Solution

Gradiant and the client partnered to complete bench-scale testing of a multi-stage solution, demonstrating proof of concept and achieving treatment objectives. Knowing that the process would need to endure the variability of influent conditions (i.e., flow, concentrations), Gradiant conducted a pilot of the customized solution to validate its efficacy and resilience. This effort would also need to ensure the plant could recover between 55-65% of the influent flow of 35,000 m³/day.

The elegant, compact solution for the complex wastewater incorporated several proprietary technologies, including:

- BioCapture for the removal of total organic carbon, ammonia, and urea, which can handle low biological loading yet unpredictable incoming wastewater flows
- FBC for the removal of hardness and phosphates, minimizing sludge production and overall solution footprint
- AFB for denitrification and total suspended solids removal, with a unique capability to handle low biological loading, yet highly variable, influent



Semiconductor



Taiwan

Fast Facts

Location:	Taiwan
End-User:	One of the World's Largest Semiconductor Manufacturers
Solution:	Industrial Wastewater & Recycling
Industry:	Semiconductor
Feedwater Source:	Combined Wastewater from semiconductor manufacturing
Technology:	Bio-Infinity: BioCapture MBBR and Anaerobic Fluidized Bed (AFB) SCE: Fluidized Bed Crystallization (FBC)
System Capacity:	35,000 m ³ /day
System Recovery:	Up to 65%
Online Date:	Commissioning (2021), Fully Online (2022)
Delivery Model:	Design-Build (DB)

Up to
65%

Wastewater Recovery



50%

Waste Reduction
using FBC
over traditional
technologies

10 years
Experience
in semiconductor
wastewater
treatment

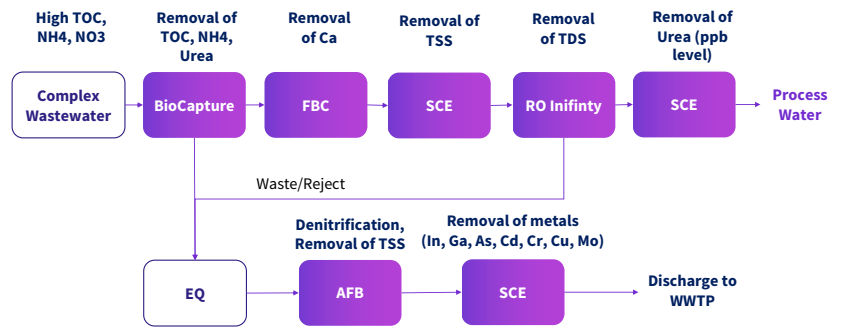


10-30%

Operational Cost
Savings compared to
Conventional Technologies

20,000

m³/day of freshwater



The Benefits

With the optimized flowsheet for reuse, the client could recover roughly 65% of this wastewater stream, potentially increasing further once the process is fully optimized.

By single-sourcing the solution with Gradiant, the client made quick, definitive design changes to enable more timely and efficient project delivery. The client anticipates being able to further increase capacity at the plant, where freshwater availability had previously been a constraint on production.

Due to the project's overwhelming success, Gradiant has established itself as the partner of choice for future water reclamation projects. Gradiant will collaborate with the client at a new fab, where the goal will also be to recycle wastewater for beneficial reuse and to achieve critical sustainability goals.



Learn More at [gradiant.com/industries/semiconductors](https://www.gradiant.com/industries/semiconductors)

Contact Gradiant today at: [gradiant.com/contact](https://www.gradiant.com/contact)

This document is for general information only. No warranty or guarantee whatsoever is given or implied and Gradiant is not bound by or liable for or by the information contained herein. Customer has the sole responsibility to determine whether the information in this document are appropriate for Customer's use, including without limitation actual site, geographical, and plant conditions, specifications, requirements, disposal, applicable laws and regulations. This document is the intellectual property of Gradiant, including but not limited to any patent or trademark contained in this document. Distribution of this document is not and does not imply any transfer of Gradiant's intellectual property.

Gradiant, the Gradiant logo, and all trade and service marks denoted with [™] and [®] are owned by Gradiant Corporation unless otherwise noted. ©2024 Gradiant.